Modelling the contribution of biogenic volatile organic compounds to new particle formation in the Jülich plant atmosphere chamber

P. Roldin\(^1\), L. Liao\(^1\), D. Mogensen\(^1\), M. Dal Maso\(^3\), A. Rusanen\(^1\), V.-M. Kerminen\(^1\), T. F. Mentel\(^4\), J. Wildt\(^5\), E. Kleist\(^5\), A. Kiendler-Scharr\(^4\), R. Tillmann\(^4\), M. Ehn\(^1\), M. Kulmala\(^1\), and M. Boy\(^1\)

\(^1\)Department of Physics, University of Helsinki, P.O. Box 64, 00014 Helsinki, Finland
\(^2\)Division of Nuclear Physics, Lund University, P.O. Box 118, 221 00 Lund, Sweden
\(^3\)Department of Physics, Tampere University of Technology, P.O. Box 692, 33101 Tampere, Finland
\(^4\)Institute for Energy- and Climate Research (IEK-8), Forschungszentrum Jülich, 52425 Jülich, Germany
\(^5\)Institute of Biogeosciences (IBG-2), Forschungszentrum Jülich, 52425 Jülich, Germany

Correspondence to: P. Roldin (pontus.roldin@nuclear.lu.se)

Received: 6 October 2014 – Published in Atmos. Chem. Phys. Discuss.: 12 November 2014
Revised: 9 September 2015 – Accepted: 11 September 2015 – Published: 28 September 2015

Abstract. We used the Aerosol Dynamics gas- and particle-phase chemistry model for laboratory CHAMber studies (ADCHAM) to simulate the contribution of BVOC plant emissions to the observed new particle formation during photooxidation experiments performed in the Jülich Plant-Atmosphere Chamber and to evaluate how well smog chamber experiments can mimic the atmospheric conditions during new particle formation events. ADCHAM couples the detailed gas-phase chemistry from Master Chemical Mechanism with a novel aerosol dynamics and particle phase chemistry module. Our model simulations reveal that the observed particle growth may have either been controlled by the formation rate of semi- and low-volatility organic compounds in the gas phase or by acid catalysed heterogeneous reactions between semi-volatility organic compounds in the particle surface layer (e.g., peroxyhemiacetal dimer formation). The contribution of extremely low-volatility organic gas-phase compounds to the particle formation and growth was suppressed because of their rapid and irreversible wall losses, which decreased their contribution to the nano-CN formation and growth compared to the atmospheric situation. The best agreement between the modelled and measured total particle number concentration \((R^2 > 0.95)\) was achieved if the nano-CN was formed by kinetic nucleation involving both sulphuric acid and organic compounds formed from OH oxidation of BVOCs.

1 Introduction

New particle formation, including formation of nano condensation nuclei (nano-CN) (McMurry et al., 2011) and their growth to larger sizes, has been observed world-wide in continental boundary layers and free troposphere (Kulmala et al., 2004; Mirme et al., 2010). Field observations, laboratory experiments and model simulations indicate that gaseous sulphuric acid (H\(_2\)SO\(_4\)) plays an important role in atmospheric nano-CN formation, yet H\(_2\)SO\(_4\) alone appears not to be able to explain all the steps of this process (Kulmala et al., 2000; Boy et al., 2003; Sipliä et al., 2010; Riipinen et al., 2007; Sihito et al., 2006; Kerminen et al., 2010; Kulmala et al., 2013, 2014). Basic compounds like ammonia and certain amines have been proposed to act as stabilizing compounds in nano-CN clusters (Berndt et al., 2010; Almeida et al., 2013; Kurtén et al., 2008), while subsequent steps of atmospheric new particle formation seem to rely on the presence of low-volatility organic compounds (LVOCs) (e.g., Metzger et al., 2010; Paasonen et al., 2010; Riipinen et al., 2012; Ehn et al., 2014; Schobesberger et al., 2013).

Oxidation products of biogenic volatile organic compounds (BVOCs) constitute the largest source of secondary organic aerosol (SOA) in the global atmosphere (Tsigaridis and Kanakidou, 2003; Hallquist et al., 2009; Spracklen et al., 2011), accounting for the main composition of SOA condensational growth (VanReken et al., 2006; Hao et al., 2009; Riipinen et al., 2012). BVOC oxidation also produces ex-
tremely low-volatility organic compounds (ELVOCs) essential to the new particle formation process in the atmosphere (Ehn et al., 2014). The most abundant group of BVOCs, accounting for more than half of their global emissions, are terpenoids (Guenther et al., 1995). Terpenoids include compounds consisting of one to several isoprene units, e.g. isoprene (C_{5}H_{8}), monoterpenes (C_{10}H_{16}), and sesquiterpenes (C_{15}H_{24}). Oxidation products of monoterpenes have substantial contribution to SOA formation (Hoffmann et al., 1997, 1998; Laaksonen et al., 2008), and low-volatility substances produced by sesquiterpene-ozone reactions may also initiate SOA formation (Bonn and Moortgat, 2003). Oxidation of isoprene leads to the formation of SOA (Suratt et al., 2006; Claey s et al., 2004), yet isoprene may also suppress the new particle formation process due to its high reactivity with OH (Kiendler-Scharr et al., 2009). Overall, the exact contribution of BVOCs to SOA still remains uncertain, especially with respect to the initial steps of atmospheric new particle formation.

In this study, we used the Aerosol Dynamics, gas- and particle-phase chemistry model for laboratory CHAMber studies (ADCHAM) (Roldin et al., 2014), to investigate the nano-CN formation and growth during a measurement campaign conducted in the Jülich Plant Atmosphere Chamber (JPAC). The in-depth analysis of the chamber measurements is discussed in another paper (Dal Maso et al., 2014). Here, we use the full chamber data set including gas and particle phase measurements, either as model input or for evaluation of the model results.

The main objectives of this work were to evaluate how well the JPAC experiments could mimic the real atmospheric conditions during new particle formation events over the boreal forest and to constrain the dominating mechanisms responsible for the nano-CN formation and growth.

2 Measurement set up

The experiments were conducted in the JPAC located at Forschungszentrum Jülich, Germany. Detailed description regarding the chamber facility was given in previous articles (e.g., Mentel et al., 2009; Schimang et al., 2006). In addition, more details about this measurement campaign can be found from Dal Maso et al. (2014). In brief, the system consisted of two borosilicate glass chambers with PTFE Teflon floors. The chambers were operated as continuously stirred tank reactors (CSTR) with Teflon fans ensuring homogeneous air mixing. Each chamber housed adjustable temperature between 10 and 50°C with a stability of ±0.5°C. The small chamber (1150 L) served as plant chamber and was connected to the larger chamber that worked as reaction chamber (1450 L, surface-area-to-volume ratio 4.87 m⁻¹).

Three small trees aging from 3 to 4 years were brought from Hyytiälä, Finland, and included Scots pine (Pinus sylvestris), Norway spruce (Picea abies), and Silver birch (Betula pendula). These trees, representing the main boreal forest species in Finland, were placed in the JPAC plant chamber for almost 2 weeks before the intensive measurement campaign started. This allowed them to adjust to the chamber environment. Starting from the day when the trees were installed in the plant chamber, tree emissions were transferred into the reaction chamber, where O₃ was added together with water vapour directly and OH was generated periodically by turning on and off the UV light, in the same fashion as applied in the intensive phase. New particles were formed every day during the UV light on periods and gases and particles deposited on the chamber walls. Discharge lamps (Osram HQI 400 W/D) were used for illumination to simulate the solar light spectrum in both chambers. Filters (OptoChem, type IR3) that reflect wavelengths between 750 and 1050 nm were used as heat shields to avoid infrared radiation inflicted plant overheating. For the model simulations we used the measured spectrum for the discharge lamps in the wavelength range of 280–650 nm and a single UV light peak at a wavelength of 254 nm which represents the UV spectrum from UV light source, a Philips, TUV 40 W lamp (Fig. S1 in the Supplement). The UV light source intensity corresponds to a O₃ to O(1D) photolysis rate of 2.9 × 10⁻³ s⁻¹ (Mentel et al., 2009).

The ambient air was purified by an adsorption dryer (Zander, KEA 70) and a palladium catalyst (450°C). O₃, NO, NO₂ and VOC levels decreased significantly after passing the purification system. The flow through the plant chamber was 115 L min⁻¹ from which a fraction of 20 L min⁻¹ was transferred to the reaction chamber. This flow was kept nearly constant by keeping the pressure drop constant. In addition, the 10 L min⁻¹ flow containing ozone was added, controlled by a second flow controller.

The concentrations of O₃, CO₂ and H₂O were measured by commercial analytical instruments. Two Gas Chromatography Mass Spectrometer (GC-MS) systems were used, one to measure the VOC concentrations from C₅ to C₂₀ in the outflow air from the plant chamber (Heiden et al., 2003), and another to identify the OH concentration by determining the decrease in the concentration of 2-butanol in the reaction chamber (Kiendler-Scharr et al., 2009). Meanwhile, the VOC concentration was continuously measured by an on-line Proton Transfer Reaction Mass Spectrometer (PTR-MS) in the plant and reaction chamber. The gas phase H₂SO₄ concentration in the reaction chamber was measured by a Chemical Ionization Mass Spectrometer (CIMS) (Petäjä et al., 2009; Mauldin et al., 1998). A prototype Airmodus Particle Size Magnifier (PSM) coupled with a TSI condensation particle counter (CPC) was used to count the total number concentration of particles larger than ca. 1.6 nm in diameter (Vanhainen et al., 2011) and a TSI CPC (TSI3022A) was used to measure the total concentration of particles larger than ca. 7 nm in diameter. A Scanning Mobility Particle Sizer (SMPS TSI3071 + TSI3025A) was used to measure the particle size distribution in the size range of 14–600 nm.
Table 1. The VOCs measured with GC-MS in the JPAC plant chamber. The measured concentrations were used as input for the ADCHAM model. The “other MTs” and “other SQTs” refer to other monoterpenes and sesquiterpenes than those specified in the table, respectively.

<table>
<thead>
<tr>
<th>Isoprene</th>
<th>α-pinene</th>
<th>β-pinene</th>
<th>myrcene</th>
<th>sabinene</th>
<th>camphene</th>
</tr>
</thead>
<tbody>
<tr>
<td>ocimene</td>
<td>Δ³-carene</td>
<td>α-terpinene</td>
<td>tricyclene</td>
<td>other MTs</td>
<td></td>
</tr>
<tr>
<td>β-phellandrene</td>
<td>terpinolene</td>
<td>α-longipinene</td>
<td>Δ-cardinene</td>
<td>other SQTs</td>
<td></td>
</tr>
<tr>
<td>farnesene</td>
<td>β-caryophyllene</td>
<td>α-pinene</td>
<td>Δ-pinene</td>
<td>α-phellandrene</td>
<td></td>
</tr>
<tr>
<td>2-butanol</td>
<td>hexanal</td>
<td>benzene</td>
<td>toluene</td>
<td>eucalyptol</td>
<td></td>
</tr>
<tr>
<td>nonanal</td>
<td>bornyl acetate</td>
<td>methyl salicylate</td>
<td></td>
<td></td>
<td></td>
</tr>
</tbody>
</table>

Figure 1. Schematic picture of the ADCHAM model structure.

The real plant emissions and the simulated day and night conditions make these experiments suitable for evaluation of methods used to describe the atmospheric transformation (ageing) of BVOCs and SOA beyond the first gas-phase VOC oxidation stage (e.g. the 2-D Volatility Basis Set (2-D VBS) Donahue et al., 2011).

3 Description of the ADCHAM model and its application

ADCHAM is a model primarily developed for simulations of laboratory chamber experiments on SOA formation and ageing. The model includes modules for reversible partitioning of organic compounds to and from the chamber walls, all fundamental aerosol dynamics processes, detailed gas- and particle-phase chemistry and a kinetic multilayer model which can be used to simulate mass transfer limited mixing of compounds in the particle phase (Fig. 1). Below we describe how ADCHAM was set up in this work. For a more detailed description of ADCHAM we refer to Roldin et al. (2014).

3.1 Gas-phase chemistry

The gas-phase chemistry reactions were selected from the Master Chemical Mechanism (MCM) v3.2 (Jenkin et al., 1997, 2012; Saunders et al., 2003) via website: http://mcm.leeds.ac.uk/MCM/. The MCM is a near-explicit chemical degradation mechanism that simplifies the chemical path of compounds by lumping products beyond the second oxidation step. We used the Kinetic Pre-Processor (KPP) version 2.1 (Damian et al., 2002) to simulate the gas-phase chemistry.

Among all the compounds measured by GC-MS in the JPAC plant chamber, 28 organic compounds were included in the gas-phase chemistry mechanism (see Table 1). In the table, the “other MTs” equals to the concentration difference between the summation of the concentrations of the 13 selected monoterpenes by GC-MS and the total monoterpene concentration measured by PTR-MS, while the “other SQTs” equals to the summation of other sesquiterpene isomers besides the listed four sesquiterpenes measured by GC-MS.

In total, the gas-phase chemistry mechanism has 2294 species and 6487 chemical and photochemical reactions for the chemical calculations. These include relevant inorganic reactions and the full MCM chemistry path for isoprene, α-pinene, β-pinene, limonene, β-caryophyllene, toluene, 2-butanol and hexanal. We also included the initial reactions of OH, O₃, and NO₂ with the following organic compounds: myrcene, sabinene, camphene, ocimene, Δ³-carene, “other MTs” (which we assumed to have the same rate coefficients as α-pinene), cineole (also known as eucalyptol), farnesene, “other SQTs” (which assumed the same rate coefficients as β-caryophyllene), α-terpinene, Δ-terpinene, α-phellandrene, β-phellandrene, and terpinolene. Furthermore, we included the initial reactions between OH and the following organic compounds: tricyclene, nonanal, bornyl acetate and methyl salicylate. Finally, the initial reactions between O₃ and the following organic compounds were included: α-humulene, α-longipinene, and Δ-cardinene. Table S1 in the Supplement lists the reaction rate coefficients that were
used for all 28 VOCs, together with references to the publications where the rate coefficients can be found. For the BVOCs with a very small contribution to the total BVOC concentration in the chamber (myrcene, sabinene, camphene, cineole, \(\alpha\)-terpinene, \(\Delta\)-terpinene, \(\alpha\)-phellandrene, \(\beta\)-phellandrene, terpinolene, tricyclene, nonanal, bornyl acetate, methyl salicylate, \(\alpha\)-longipinene and \(\alpha\)-humulene), the initial reaction was only considered as a sink of OH, \(O_3\) and \(NO_3\), without any other influence on the MCM gas-phase chemistry scheme. The oxidation of the sesquiterpenes farnesene, \(\Delta\)-cardinene and “other SQTs” were treated in a similar manner, except that we assumed that on average \(\frac{1}{2}\) OH molecule was formed for each sesquiterpene molecule that reacted with \(O_3\). To only consider the first oxidation reactions of some of the BVOCs influence the predicted radical and ozone concentrations. However, because the concentrations of these BVOCs were relatively low this effect was most likely small.

Ocimene constituted a major fraction of MT on the first experiment day. The chemistry path for ocimene is not available in the MCM. However, we included the ocimene chemistry by approximating its chemistry beyond the first oxidation step with that of limonene, for which the full MCM chemistry is available. We also approximated the chemistries of \(\Delta\)-longipinene and \(\alpha\)-humulene), the \(\Delta\)-3-carene after the first oxidation step with that of \(\alpha\)-pinene, since both are bicyclic monoterpenes with an endocyclic double bond, as was done by Boy et al. (2013). For the “other MTs”, we approximated the chemistry beyond the first oxidation step assuming that 50 % of the oxidation products end up as the corresponding MCM \(\alpha\)-pinene first generation oxidation products and 50 % end up as the corresponding MCM \(\beta\)-pinene first generation oxidation products.

Based on the recent finding of rapid formation of extremely low-volatility organic compounds (ELVOCs) from ozonolysis of monoterpenes containing endocyclic double bonds (Ehn et al., 2014) we also included a simplified ELVOC formation mechanism in the MCM gas-phase chemistry code (Reaction R1), assuming that 7 mole % of the \(\alpha\)-pinene + \(O_3\) and \(\Delta\)-3-carene + \(O_3\) oxidation products were ELVOCs, with a molar mass of 325 g mol\(^{-1}\) and a vapour pressure of \(10^{-10}\) Pa, which approximately corresponds to the VBS bin of \(\log_{10}(C^*/\mu g m^{-3}) = -5\). We also performed simulations where we considered that ELVOCs were formed from ozonolysis of any monoterpene or sesquiterpene, with the same ELVOC molar yield as for \(\alpha\)-pinene. MCM\(_{ox, prod}\) represents the MCMv3.2 oxidation products that were formed from the same reactions as the ELVOCs but via a different reaction pathway.

\[
\text{VOC} + \text{O}_3 \rightarrow 0.07\text{ELVOC} + 0.93\text{MCM}_{\text{ox, prod}}. \quad (R1)
\]

Ehn et al. (2014) also observed ELVOC formed from OH-oxidation of \(\alpha\)-pinene with an estimated maximum molar yield of 1 %. In this work we evaluated the potential contribution of ELVOCs formed from OH-oxidation by using an ELVOC molar yield of 1 % for any monoterpene and sesquiterpene that reacts with OH (Reaction R2).

\[
\text{VOC} + \text{OH} \rightarrow 0.01\text{ELVOC} + 0.99\text{MCM}_{\text{ox, prod}} \quad (R2)
\]

In order to evaluate the potential influence of specific ELVOCs (e.g. dimers) which may be involved in the nano-CN formation (here denoted ELVOC\(_{\text{nucl}}\)) we also included the possibility to add separate reactions where the monoterpene and sesquiterpene (VOC\(_{\text{MT/SQT}}\)) that react with \(O_3\) or OH form trace amounts of ELVOC\(_{\text{nucl}}\) (Reaction R3 and R4). In order to have little influence on the gas-phase chemistry or SOA formation, we used a very low \(\text{ELVOC}_{\text{nucl}}\) yield (\(\gamma_{\text{ELVOC}}\)) of 0.001 mole % and scaled the nucleation rate coefficient accordingly.

\[
\text{VOC}_{\text{MT/SQT}} + \text{O}_3 \rightarrow \gamma_{\text{ELVOC}}\text{ELVOC}_{\text{nucl}} + (1 - \gamma_{\text{ELVOC}})\text{MCM}_{\text{ox, prod}} \quad (R3)
\]

\[
\text{VOC}_{\text{MT/SQT}} + \text{OH} \rightarrow \gamma_{\text{ELVOC}}\text{ELVOC}_{\text{nucl}} + (1 - \gamma_{\text{ELVOC}})\text{MCM}_{\text{ox, prod}} \quad (R4)
\]

The Reactions (R3) and (R4) were only used in those simulations where ELVOC\(_{\text{nucl}}\) were involved in the nano-CN formation (Eqs. 3–6).

### 3.2 Aerosol dynamics

The aerosol dynamics module in ADCHAM is based on the aerosol dynamics code from the 2-D Lagrangian model for Aerosol Dynamics, gas-phase CHEMistry and radiative transfer (ADCHEM) (Roldin et al., 2011). It includes subroutines for nano-CN formation, condensation/evaporation, Brownian coagulation and particle deposition onto the chamber walls. ADCHAM simulates the condensation, dissolution and evaporation of sulphuric acid, ammonia, nitric acid, hydrochloric acid and an unlimited number of organic compounds using the analytic prediction of condensation scheme (Jacobson, 1997) and prediction of non-equilibrium growth scheme (Jacobson, 2005). The aerosol particle water content is calculated with a thermodynamics model (Sect. 3.4).

ADCHAM considers the deposition of particles onto the chamber walls and keeps track of the amount of deposited material on the walls. In Roldin et al. (2014) we kept track of each compound in each particle size bin that deposited on the chamber walls, and explicitly simulated the mass-transfer-limited gas-particle partitioning between the gas phase and the wall-deposited particles, assuming that the particles deposited on the walls remain as spherical particles on the walls. In this work, we instead assumed that the deposited SOA particles lose their individual particle identity and merge into the VOC wall matrix together with the gas-phase VOCs that deposit directly to the chamber walls (Sect. 3.5). During the JPAC experiments the particles were formed by nucleation and, as a result of coagulation, wall losses.
and dilution, their average lifetime in the chamber was relatively short (less than 45 min, wherein dilution generally is the dominant loss process). Therefore, we expect that most of the formed particles were under charged with respect to the Boltzmann charge equilibrium distribution so that we do not have to consider the enhanced deposition rates induced by the particle charge (McMurry and Rader, 1985; Pierce et al., 2008; Roldin et al., 2014). Thus, we calculated the first order wall deposition loss rate assuming that all particles were unchanged using the indoor deposition loss rate model from Lai and Nazaroff (2000), which accounts for different deposition loss rates on upward-, downward- and vertically facing surfaces. In the model by Lai and Nazaroff (2000) the fundamental (but unknown) parameter for the particle loss rate is the friction velocity, $u^*$. In this work we found that with a relatively small value of $u^*$ (0.02 m s$^{-1}$), the model best captures the observed particle number and particle volume concentration loss rates after the UV light is turned off. With this value of $u^*$ the deposition loss rate is equal to the observed ELVOC molecule loss rate measured by Ehn et al. (2014) when the particle (molecule) diameter is equal to 0.8 nm. We therefore used the value of $u^* = 0.02$ m s$^{-1}$ for all the model results presented in this work.

We evaluated six nano-CN formation parameterizations (Eqs. 1–6) and compared them against base-case simulations with a fixed nano-CN formation rate ($J$). The first mechanism (Eq. 1) is sulphuric acid activation nucleation (Kulmala et al., 2006), Eq. (2) is used for kinetic nucleation of two H$_2$SO$_4$ molecules (McMurry and Friedlander, 1979), Eq. (3) is used for kinetic nucleation of one H$_2$SO$_4$ molecule and one ELVOC$_{nucl}$. Eq. (4) is the nano-CN parameterization proposed by Riccobono et al. (2014) based on experiments in the CLOUD chamber, Eq. (5) represents a mechanism where single ELVOCs serve as nano-CN (Ehn et al., 2014), and Eq. (6) represent a kinetic type of nucleation mechanism with ELVOC$_{nucl}$.$$

\begin{align*}
J &= A_1 [H_2SO_4] \quad (1) \\
J &= K_2[H_2SO_4]^2 \quad (2) \\
J &= K_3[H_2SO_4][ELVOC_{nucl}] \quad (3) \\
J &= K_4[H_2SO_4]^2[ELVOC_{nucl}] \quad (4) \\
J &= A_5 [ELVOC_{nucl}] \quad (5) \\
J &= K_6[ELVOC_{nucl}]^2 \quad (6)
\end{align*}

A (s$^{-1}$) and $K$ (cm$^3$ s$^{-1}$) in Eqs. (1)–(3) and (5)–(6) are formation rate coefficients for activation type and kinetic type of nucleation, respectively. For Eq. (4) the formation rate coefficient has the unit cm$^6$ s$^{-1}$.

The composition of the nucleation clusters was chosen in order to match the respective new particle formation mechanism. The dry nano-CN volume was composed of equal mole fractions of H$_2$SO$_4$ and ELVOC$_{nucl}$ when we used Eqs. (1), (3) or (5), equal mole fractions of H$_2$SO$_4$ and NH$_3$ when we used Eq. (2), and pure ELVOC$_{nucl}$ when we used Eq. (6). The molar mass of ELVOC$_{nucl}$ was assumed to be 500 g mol$^{-1}$. The equilibrium water content of the nano-CN clusters was calculated with the thermodynamics model. The dry particle size of the nano-CN was assumed to be 1.5 nm.

Both ELVOC$_{nucl}$ and H$_2$SO$_4$ were assumed to be nonvolatile. The ELVOC$_{nucl}$ first order wall loss rate was 0.011 s$^{-1}$ according to Ehn et al. (2014). The ELVOC$_{nucl}$ condensation sink was modelled explicitly with the condensation algorithm in ADCHAM. Chemical degradation of ELVOC$_{nucl}$ was not considered.

The ELVOC$_{nucl}$ involved in the nano-CN formation were assumed to be formed instantaneously after the first oxidation stage of monoterpene and sesquiterpene (Reactions R3 and R4). With Eqs. (3) and (4) we investigated six different sources of ELVOC$_{nucl}$: (i) as a product formed exclusively from the ozonolysis of endocyclic monoterpenes (α-pinene and Δ$^3$-carene), (ii) from the ozonolysis of all monoterpenes and sesquiterpene, (iii) from the ozonolysis of sesquiterpenes, (iv) from the OH and O$_3$ oxidation of monoterpenes and sesquiterpenes, (v) when monoterpenes and sesquiterpenes react with OH, or (vi) when sesquiterpenes react with O$_3$ or OH. When using Eqs. (5) and (6) we only considered the ELVOC$_{nucl}$ that was formed from monoterpenes and sesquiterpenes reacting with OH.

### 3.3 Size distribution structures

ADCHAM can be operated with the full-moving, fixed-sections or moving-centre particle size distribution approach (Roldin et al., 2011). In this work, we have tested both the fixed-sections approach and full-moving method using different numbers of size bins. The largest advantage of the full-moving approach compared to the fixed-sections approach is that it does not introduce any numerical diffusion problems during condensation/evaporation because it allows the particles to grow/shrink to their exact size. The main disadvantage is that new particle size bins need to be introduced when new particles are formed. In this work, we handled this by only introducing new particles formed by nucleation once every minute and at the same time as we added a new size bin for the freshly nucleated particles, we also removed the size bin containing the largest (oldest) particles. In order to not remove any particles within a time frame substantially longer than their average residence time in the reaction chamber, which was about 45 min, we used 400 size bins for the full-moving approach. Thus, with this method we kept track of the nucleated particles for 400 min (almost 9 times the average residence time in the chamber), before they were removed from the modelled size distribution. This method was compared with the fixed-section approach using a different number of size bins in the diameter ($D_p$) range 1.5–800 nm. Based on these tests we could conclude that the fixed-section approach was not suitable due to numerical diffusion if the number of size bins were less than 400 (Fig. S2). With the full-moving approach the particle volume (PV) and particle...
number concentrations (PN) were well conserved although the last size bin was removed once every minute (Fig. S3). Therefore, we decided to use the full-moving method to represent the particle number size distribution in this work.

One difficulty with the full-moving method is that the particle number size distribution needs to be mapped back onto a fixed diameter grid in order to illustrate it as a dPN/dlog\(D_p\) distribution. This grid needs to be relatively coarse in order to not get a “jumpy” graphical representation of the particle number size distribution. For this we used 50 size bins between 1.5 and 360 nm in diameter.

### 3.4 Particle phase chemistry and phase-state

ADCHAM includes a detailed particle-phase chemistry module, which is used to calculate the particle equilibrium water content, the particle acidity, nitric acid and hydrochloric acid equilibrium vapour pressures for each particle size bin, and the non-ideal interactions between organic compounds, water and inorganic ions using the activity coefficient model AIOMFAC (Zuend et al., 2008, 2011). In this work, we did not model the specific interactions between the organic and inorganic compounds but assumed a complete phase-separation of the inorganic and organic particle phase. We used AIOMFAC to calculate the equilibrium water content in both the inorganic and organic particle phase and the individual compound activity coefficients. The organic compound activity coefficients were used when deriving the organic compounds equilibrium vapour pressures above each particle size (Sect. 3.6).

The particle phase chemistry module also contains subroutines that can be used to calculate organic salt formation, oligomerization and heterogeneous oxidation (Roldin et al., 2014). Recently, Shiraiwa et al. (2013) illustrated what peroxyhemiacetal (PHA) formation between organic compounds containing aldehydes and hydroperoxide functional groups may proceed fast and contribute to a large and rapid increase of the formed SOA mass during photooxidation experiments. In this work we evaluate if this type of heterogeneous dimer formation mechanism may explain the observed nano-particle growth during the JPAC experiment. For this we tested to use a constant value of the PHA formation rate \(k_{\text{PHA}}\) of 12 M\(^{-1}\) s\(^{-1}\) adopted from Shiraiwa et al. (2013). We also tested to model \(k_{\text{PHA}}\) as a parameterization of the sulphate particle mole concentration \(x_{\text{SO}_4^{2-}}\), assuming that the PHA formation is acid catalysed by the co-condensing \(\text{H}_2\text{SO}_4\) (Eq. 7).

\[
k_{\text{PHA}} = B \cdot x_{\text{SO}_4^{2-}} \text{(M}^{-1}\text{s}^{-1}).
\]  

(7)

Here \(B\) is a constant, the value of which we varied in the range 1–500 M\(^{-1}\) s\(^{-1}\). In this work we used the kinetic multi-layer module in ADCHAM for investigating whether the phase-state of the SOA particles might have influenced the evolution of the particle number size distribution. In order to do this, we divided each particle into three layers (an approximately monolayer thick surface layer of 0.7 nm, and two bulk-layers). We considered the two extreme conditions where the SOA particles either were considered to be completely liquid-like (no concentration difference between the surface and bulk layers) or solid-like (no molecule transport between the surface and the particle bulk layers). Still, this had only a minor effect on the modelled particle growth (SOA formation), but by treating the SOA as solid-like improved the agreement between the modelled and measured SOA particle volume decay when the UV light was turned off (Fig. S4). Thus, in the simulations used to produce the results presented in Sect. 4, we treated the SOA particles as solid-like with the assumption that the molecule transport between the particle bulk and the particle surface-layer is relatively slow compared to the time scale it takes for the condensation to form a new monolayer thick surface layer. However, it is important to mention that the effect of the SOA phase-state cannot be unambiguously distinguished from the effect of the SOA volatility when only looking at total particle volume loss rates.

### 3.5 Reversible VOC wall loss

The JPAC reaction chamber was mixed with a Teflon fan with mixing times <2 min. The first order VOC wall loss rate to the chamber walls \((k_w)\) was therefore governed by the molecular diffusion across the boundary layer near the chamber walls and by the uptake rate at the wall surface. According to McMurry and Grosjean (1985), the first order VOC wall loss rate for FEP Teflon films \((k_{w,FEP})\) can be modelled with Eq. (8), which has two key parameters; the VOC wall mass accommodation coefficient \((\alpha_w)\) and the coefficient of eddy diffusion \((k_e)\). Unfortunately neither \(\alpha_w\) or \(k_e\) can be derived easily. Based on the observed wall losses of particles, McMurry and Radar (1985) estimated \(k_e\) to be 0.12 s\(^{-1}\) in a 60 m\(^3\) FEP Teflon film chamber. Zhang et al. (2015) estimated \(k_e\) to be 0.075 and 0.015 s\(^{-1}\) in two not actively mixed FEP Teflon film chambers with volumes of 24 and 28 m\(^3\).

\[
k_{w,FEP} = \frac{A_w}{V_{\text{chamber}}} \left(\frac{\alpha_w \bar{\nu}}{1 + \left(\frac{2}{5} \alpha_w \bar{\nu}/(4\sqrt{k_eD})\right)}\right).
\]  

(8)

Here \(A_w\) is the chamber wall surface area, \(V_{\text{chamber}}\) is the chamber volume, \(\bar{\nu}\) is the mean thermal speed of the gas molecules and \(D\) is the molecular diffusion coefficient.

In the JPAC reaction chamber Ehn et al. (2014) observed ELVOC first order wall loss rates in the range 0.013–0.011 s\(^{-1}\). By inserting a value of 0.011 s\(^{-1}\) for \(k_{w,FEP}\) in Eq. (8) and assuming that the surface wall uptake rate is not limiting the ELVOC wall loss rate \((\alpha_w > 10^{-6})\) we get a \(k_w\) of 4.2 s\(^{-1}\) for the JPAC reaction chamber. This value is substantially larger than what was estimated by Zhang et al. (2014) and McMurry and Radar (1985) and is probably because the JPAC reaction chamber was actively mixed and has a smaller volume.
From measurements in a 4 m$^3$ FEP Teflon chamber Kokkola et al. (2014) observed that for nopinone which has a pure-liquid equilibrium saturation vapour pressure ($P_0$) of 53 Pa, the gas-wall equilibrium was reached within a few minutes and $k_{w,FEP}$ was $>0.03$ s$^{-1}$. The observations by Ehn et al. (2014) and Kokkola et al. (2014) indicate that gas-wall equilibrium can be reached rapidly for both volatile and low-volatile VOCs and that their uptake on the chamber walls is primarily limited by the transport to the chamber walls and not by surface uptake ($\alpha_w$). In contrast, Zhang et al. (2015) observed that the gas-phase concentration of 25 different oxidized VOCs ($P_0 = 6 \times 10^{-6} - 20$ Pa) slowly decreased over more than 18 hours without reaching gas-wall equilibrium. These experiments were performed in a 24 m$^3$ FEP Teflon film chamber that was not actively mixed. Based on Eq. (8), Zhang et al. (2015) concluded that the VOC wall loss rate onto the FEB Teflon film walls was primarily limited by the surface uptake ($\alpha_w$) and not by the molecule diffusion to the chamber walls. Zhang et al. (2015) also derived a parameterization of $\alpha_w$ as a function of the compounds pure liquid equilibrium saturation vapour pressure.

Based on the rapid ELVOC wall losses observed by Ehn et al. (2014), we assumed that the VOC losses to the JPAC reaction chamber walls was primarily governed by the molecule diffusion to the chamber walls and used a constant $k_w$ equal to 0.011 s$^{-1}$ for all condensable organic compounds. However, we also performed test simulations using Eq. (8) and the $\alpha_w$ parameterization from Zhang et al. (2015).

According to Matsunaga and Ziemann (2010) the loss rate of VOCs from FEP Teflon chamber walls back to the gas phase ($k_g$ (s$^{-1}$)) can be represented by Eq. (9),

$$k_{g,i} = \frac{k_w}{RT/P_0,i\gamma_{w,i}}$$

where $C_w$ in Eq. (9) is an effective mole concentration of organic compounds on the chamber walls (mol m$^{-3}$) and $\gamma_{w,i}$ is the activity coefficient of compounds $i$ in the organic film on the chamber walls, $T$ is the temperature in Kelvin and $R$ is the universal gas constant (J mol$^{-1}$ K$^{-1}$). According to Matsunaga and Ziemann (2010), the FEP Teflon film walls serve as a large organic pool where VOCs can absorb ($C_w/\gamma_{w,i}$ on the order of 100 µmol m$^{-3}$). Thus, the actual VOCs deposited on the chamber walls is considered to have a negligible contribution to $C_w$.

We assumed that there was practically no $C_w$ on the glass for the VOCs to dissolve into. We also estimated that even if the deposited VOCs and SOA were distributed as a molecule monolayer on the walls, the VOCs formed during the simulated experiment could only cover a maximum 2% of the total glass wall surface area in the end of the measurement campaign (see Supplement). Thus, we assumed that the VOC losses onto the glass wall surfaces could be treated as a condensation process but without dissolution (absorption) into an organic matrix on the walls. With this approach the uptake of compound $i$ is governed by the difference between the concentration in the gas phase ($c_{g,i}$) and the pure liquid equilibrium saturation concentration ($c_{0,i}$) (Eqs. 10–11). Thus, as long as $c_{g,i} < c_{0,i}$ the VOC will not condense on the glass walls. For many of the semi-volatility organic compounds (SVOCs), the limit at which $c_{g,i}$ become larger than $c_{0,i}$ was never reached during the experiments.

$$\frac{dc_{g,i}}{dt} = -k_w (c_{g,i} - c_{0,i}) \quad \text{if} \quad c_{g,i} > c_{0,i} \quad \text{or} \quad c_w < 0$$

$$\frac{dc_{w,i}}{dt} = k_w (c_{g,i} - c_{0,i}) \quad \text{(11)}$$

For the PTFE Teflon floor, we used the theory developed for FEP Teflon films (Eqs. 9, 12 and 13), assuming that the PTFE Teflon surface (in total 15% of the total chamber surface area) has a $C_w/\gamma_{w,i} = 100$ µmol m$^{-3}$ and $k_{w,i} = 1.7 \times 10^{-3}$ s$^{-1}$ (0.15 $\times$ 0.011 s$^{-1}$).

$$\frac{dc_{g,i}}{dt} = -k_{w,i} c_{g,i} + k_g,i c_{w,i}$$

$$\frac{dc_{w,i}}{dt} = k_{w,i} c_{g,i} - k_g,i c_{w,i}.$$  \hspace{1cm} (13)

In order to mimic the actual experiment procedure (Sect. 2), we started the model simulations by running ADCHAM 14 days prior to the actual experiments started, with conditions similar to Day 1 of the experiment campaign (see Sect. 3.7). This allowed the VOC concentration to build up on the chamber walls.

### 3.6 Condensable organic compound properties

In this work, we used three different approaches to simulate the SOA formation. In the first approach, the SOA formation was modelled by considering the gas-particle partitioning of all non-radical organic compounds from the MCMv3.2 gas-phase chemistry code with estimated pure-liquid equilibrium saturation vapour pressure lower than 10$^{-2}$ Pa at $T = 289$ K (in total 488 compounds). The pure-liquid equilibrium saturation vapour pressures of these compounds were estimated using the boiling point and vapour pressure extrapolation method from Nannoolal et al. (2004, 2008), hereafter referred to as the Nannool method. MCMv3.2 only includes one sesquiterpene: β-caryophyllene. As an attempt to take into account the SOA formation from the other sesquiterpenes, exclusively in these simulations all the sesquiterpenes were assumed to be emitted as β-caryophyllene. In this work we will refer to this SOA formation representation as the MCM compound SOA formation mechanism.

The second method is the 2-D VBS approach (Jimenez et al., 2009; Donahue et al., 2011), which is a simplified approach to describe how the volatility distribution of the VOCs (as a function of their Oxygen to Carbon ratio (O:C)) evolves beyond the first oxidation step. A detailed description of the structure and general assumptions of the 2-D VBS method used in ADCHAM is given by Hermansson et al. (2014). Here we primarily describe how the 2-D VBS was...
modified in order to better capture the SOA formation observed during the JPAC experiments.

The 2-D VBS compounds were distributed across 11 volatility classes separated by powers of 10 in equilibrium saturation concentration (at the standard temperature 298 K \(C_{298}^0\)), ranging from \(10^{-7}\) to \(10^3\) \(\mu g\) m\(^{-3}\), and 12 discrete O : C from 0.1 to 1.2, in steps of 0.1. VOCs were introduced into the 2-D VBS by scaling the amount of reacted monoterpens and sesquiterpenes with stoichiometric VBS yield parameters that represent the volatility distribution of the first generation oxidation products. We used the parameterizations from Table 3 in Henry et al. (2012). These parameterizations represent the first generation product volatility distributions formed during experiments where \(\alpha\)-pinene was primarily oxidized by ozone (no OH-scavenger) or where \(\alpha\)-pinene was oxidized by OH. We used the former parameterization to represent the first generation terpene (monoterpens and sesquiterpenes) oxidation products during the UV off periods and the later for the UV light on periods. ELVOCs formed as first generation oxidation products from Reaction (R1) were introduced into the 2-D VBS assuming that they had a O : C of 1 and \(C_{298}^* = 10^{-7}\) \(\mu g\) m\(^{-3}\).

Hermansson et al. (2014) illustrated that the modelled SOA formation is sensitive to the volatility distribution and the assumed O : C of the first generation oxidation products. Moreover it depends on how the functionalization and fragmentation pattern is represented in the VBS and the reaction rate constant between the VOCs and OH. Equation (14) from Jimenez et al. (2009) was used to represent how the fraction of VOCs which fragmentize upon oxidation varies as a function of their O : C.

\[ f_{\text{frag}} = (O : C)^y. \]  

(14)

Jimenez et al. (2009) assumed that \(y\) was equal to 1/6, that the 2-D VBS compounds were oxidized by OH with a reaction rate coefficient \(k_{\text{OH}}\) of \(3 \times 10^{-11}\) cm\(^3\) s\(^{-1}\), and that the compounds that fragmentize had equal probabilities to split at any of the carbon bonds. However, with this 2-D VBS setup, ADCHAM substantially overestimated the SOA formation (Fig. S5). This was mainly because a substantial fraction of the 2-D VBS fragmentation products was still less volatile than the reacting VOCs. If we instead assumed that all fragmenting compounds (on a mole fraction basis with equal proportions) end up into the VBS bins where \(C_{298}^*\) is at least 3 orders of magnitude larger than the corresponding functionalization products, and decreased the probability of fragmentation somewhat \((y = 1/3)\), the modelled particle volume concentration agreed better with the measurements (Fig. S6). Thus, in the proceeding sections we used this fragmentation parameterization. We also performed sensitivity tests where we varied the value of \(k_{\text{OH}}\) in the range of \(3 \times 10^{-11}\) to \(5 \times 10^{-11}\) cm\(^3\) s\(^{-1}\) and the O : C of the first generation oxidation products in the range of 0.3–0.5 (Fig. S6). Based on these tests, we decided to use the values of \(k_{\text{OH}} = 5 \times 10^{-11}\) cm\(^3\) s\(^{-1}\) and O : C = 0.4 for the first generation oxidation products in the simulations used to produce the results in Sect. 4.

The temperature dependence of the 2-D VBS equilibrium saturation concentrations were derived using the Clausius Clapeyron equation and assuming the following form for the heat of vaporization \((\Delta H;\) Epstein et al., 2010):  
\[ \Delta H = -11 \cdot \log_{10} C_{300}^* + 129 \text{kJ mol}^{-1}. \]  

(15)

As the third approach we also tested to represent the SOA formation with a one-product model. With this method, only a single non-volatile condensable organic compound was used to represent the SOA formation. This compound was formed as a first generation oxidation product when any of the monoterpenes or sesquiterpenes reacted with \(O_3\) or OH, assuming a molar yield of 25%. The non-volatile condensable organic compound was assumed to have a molar mass of 325 g mol\(^{-1}\). This simulation represents the limiting condition where the SOA formation is purely kinetically limited and not absorption partition limited, and it was also used for estimating how large the ELVOC yield would need to be if the particles were only growing by condensation of ELVOCs.

Both with the 2-D VBS and when the MCM compounds were used to represent the condensable organic compounds, the Raoult’s law and the Kelvin equation were used to calculate the equilibrium vapour pressure \((p_{\text{v},i,j})\) for each compound \(i\) above each particle size \(j\) (Eq. 16). With the 2-D VBS we assumed that the organic compounds were mixed ideally (unity activity coefficients \((\gamma_i)\)). However, for the MCM compounds the molecule structure is known, so we calculated the organic compound activity coefficients in the SOA particle mixtures using AIOMFAC.

\[ p_{\text{v},i,j} = p_{0,i}x_i\gamma_i e^{ \left( \frac{4\pi M_i\sigma_i}{\rho\sigma_j^3}\right)}, \]  

(16)

where \(x_i,j\) is the mole fraction of compound \(i\) in the particle surface layer of particles in size bin \(j\), \(M_i\) is the molar mass of compound \(i\) and \(\rho\) is the density of the absorbing phase. In this work the surface tension of the organic compounds \((\sigma_j)\) was estimated to be equal to 0.05 N m\(^{-1}\) following Ripipinen et al. (2010), even though we also tested the values of \(\sigma_i\) in the range 0.02–0.07 N m\(^{-1}\). These sensitivity tests revealed that the modelled total particle number concentration decreased by approximately 10% and the total particle volume concentration by approximately 30% when the value of \(\sigma_i\) was increased from 0.02 to 0.07 N m\(^{-1}\) (Fig. S7).

### 3.7 Optimizing model input parameters

We used the ADCHAM model to simulate the nano-CN formation and growth during one measurement campaign conducted in the JPAC chamber. We chose to study the first 4 continuous days from the measurement campaign because these days had continuous measurements, coverage of the data set was complete and UV light-on period was the same.
The measured temperature and relative humidity (RH) in the JPAC reaction chamber were used directly in the model as input. The values from the first 4 days are illustrated in Fig. 2. The purple bars in the figures illustrate the UV on periods. The temperature stabilized around noon on Day 1, after that the temperature was ca. 16°C for all days. The RH had minor fluctuations during the experiment. RH was kept to ca. 60% during UV on periods for the first 3 days. On Day 4, the RH was around 55%. In addition, eight discharge lamps were used to simulate solar illumination on Day 1 in the plant chamber, but only four lamps were used on the remaining days to generate lower levels of VOC emissions from the trees.

Because the inflow of ambient air into the JPAC chamber was purified by an adsorption dryer, by default, the concentrations of NO, NO₂, SO₂, and CO in the inflow to the reaction chamber were assumed to be 0.03, 0.2, 0.015 and 15 ppbv, respectively. However, in order to evaluate how sensitive the model results were, in particular the modelled VOC composition and SOA formation, we also performed sensitivity tests where we varied the inflow concentrations of NOₓ (NO + NO₂) within the range of 0.05–1 ppbv. Concentrations of VOCs in the inflow to the reaction chamber were based on the GC-MS and PTR-MS data. The initial concentrations of all VOCs were set to zero. The measured concentrations of isoprene, monoterpenes and sesquiterpenes (in the plant chamber) are illustrated in Fig. 3. The monoterpenes and sesquiterpene concentrations displayed a certain diurnal distribution pattern, because the discharge lamps mimicked sunlight in the plant chamber. The total monoterpen concentration exceeded 4 ppbv on Day 1, and then decreased to a value below 2 ppbv in the following 3 days. In particular, the ocimene concentration was the highest on Day 1, which can be explained by the fact that ocimene emission is light-dependent (Owen et al., 2002), and the simulated solar light intensity in the plant chamber from the discharge lamps was two times higher on Day 1 than during Day 2–Day 4.

The isoprene concentration and the total sesquiterpene concentration were about an order of magnitude lower than the monoterpen concentration. Overall, the measured concentrations of terpenes were at similar levels as ambient air concentrations in boreal forest environments (Ruuskanen et al., 2009).

At the first attempt, we tried to simulate the O₃ and OH concentrations with the gas-phase chemistry mechanism. An OH sink has been determined in the empty chamber by direct OH-LIF measurements (Broch, 2011) and has been always found to be within 2–4 s⁻¹. However, even with an OH sink of 4 s⁻¹, the model could not capture the observed gradual decrease in the O₃ concentration and increase in OH concentration during the UV light on periods without either varying the UV light intensity or the OH sink (Fig. 4).

Therefore, we decided to use the measured O₃ and H₂SO₄ concentrations, and estimated OH concentration, as input to
the model for the simulations presented in Sect. 4. Figure 4a shows the measured O$_3$ concentration during the experiment, Fig. 4b shows the estimated OH concentration based on the observed loss rate of 2-butanol and Fig. 4c shows the measured H$_2$SO$_4$ concentration. When the UV light was turned on the H$_2$SO$_4$ concentration increased very rapidly and had a distinct peak. This is most likely due to an initial peak in the OH concentration at the moment when the UV lamps were turned on (indicated by the modelled OH concentration). In the model we represented this by setting the OH concentration to $5 \times 10^7$ molecules cm$^{-3}$ for the 12 first minutes after the UV light was turned on.

The photolysis rates were simulated by using the quantum yields and absorption cross sections reported at the MCMv3.2 web site. In order to evaluate the direct influence of the 254 nm wavelength UV light on the VOC composition and SOA formation, we performed model simulations where the 254 nm UV light was not considered when calculating the photolysis rates ($J_x$) for all compounds except O$_3$. These tests showed that the modelled condensable organic compound composition, O$_3$ concentration (Fig. 4a), OH concentration (Fig. 4b) and the SOA formation were not significantly influenced directly by the 254 nm UV light source, but strongly by the OH generated from the photolysis of O$_3$. Apart from O$_3$, the compound that was affected most by the 254 nm wavelength UV light was H$_2$O$_2$ ($J_{\text{H}_2\text{O}_2} = 1.26 \times 10^{-4}$ s$^{-1}$ with the UV light source and $J_{\text{H}_2\text{O}_2} = 3.72 \times 10^{-8}$ s$^{-1}$ without the UV light source). Some of the VOCs containing carbonyl groups and nitrate groups were also influenced by the UV light source. The most prominent change in the modelled photolysis rate in these two groups of VOCs occurred for glyoxal (a dialdehyde) ($J_{\text{glyoxal}} = 2.93 \times 10^{-5}$ s$^{-1}$ with the UV light source and $J_{\text{glyoxal}} = 5.04 \times 10^{-7}$ s$^{-1}$ without the UV light source) and methyl nitrate (CH$_3$NO$_3$) ($J_{\text{CH}_3\text{NO}_3} = 5.89 \times 10^{-5}$ s$^{-1}$ with the UV light source and $J_{\text{CH}_3\text{NO}_3} = 2.51 \times 10^{-8}$ s$^{-1}$ without the UV light source). These values can be compared with the rates at which glyoxal and CH$_3$NO$_3$ were oxidized by OH. At the OH concentration of $5 \times 10^7$ molecules cm$^{-3}$ (typical for the UV light on periods) this rate was $5.00 \times 10^{-4}$ s$^{-1}$ for glyoxal and $1.08 \times 10^{-6}$ s$^{-1}$ for CH$_3$NO$_3$. Thus, for glyoxal the reaction with OH was still $\sim 10$ times faster than the photolysis reaction rate, while for CH$_3$NO$_3$ the photolysis reaction rate was $\sim 2$ times larger than the rate at which CH$_3$NO$_3$ was oxidized by OH. This indicates that short wavelength UV light sources (as the one used in JPAC) may influence the VOC composition, especially if a large fraction of the VOCs contain nitrate functional groups (i.e. at high NO$_x$ concentrations).
Figure 4. Measured and modelled (a) O$_3$ concentrations, (b) OH concentration, and (c) H$_2$SO$_4$ concentration. The OH concentration (red +) was not measured directly but was derived from the observed 2-butanol loss rate. The model results are from the simulations where the O$_3$, OH and H$_2$SO$_4$ concentrations were simulated by the model instead of given as the input concentration to the model. The results given by the orange dashed line corresponds to a simulation where the 254 nm UV light was only used to calculate the photolysis rates of O$_3$ but not influencing photolysis rates of the other compounds. In the model simulations, we used the empirically determined JPAC reaction chamber-specific OH sink of 4 s$^{-1}$ and an O$_3$ concentration of 170 ppbv in the inflow to the chamber. The blue lines give the model input concentrations that were used for the simulations presented in Sect. 4. For O$_3$ and H$_2$SO$_4$, the model input concentration was taken directly from the measurements.

4 Results and discussion

Table 2 summarizes the different model tests that we performed in this work in order to constrain the VOC wall losses, the aerosol dynamics-, gas- and particle-phase chemistry mechanisms that can explain the nano-CN formation and growth observed during the JPAC experiments presented in Sect. 2.

4.1 Time series of BVOC concentrations

To investigate the potential contribution of BVOCs to the nano-CN formation and growth, it is essential to properly predict the time series of the BVOC concentrations. The modelled isoprene, monoterpene, and sesquiterpene concentrations in the JPAC reaction chamber are plotted in Fig. 5, together with isoprene and total monoterpene concentrations measured by the PTR-MS. The modelled isoprene concentrations were in a good agreement with the measurements during the UV off period on Day 1. During the rest of the simulated 4-day period, the simulated isoprene concentration was generally lower than the observations. However, considering the low isoprene concentrations and the uncertainties in the PTR-MS measurements, we cannot draw any conclusions on whether the model actually underestimates the isoprene concentration or not.

The summation of the modelled monoterpene isomer concentrations reached the same level as the measurements. During the dark periods, the monoterpene concentrations in the reaction chamber decreased to about one third of their concentrations measured in the plant chamber. This was because of the in-flow dilution and chemical reactions with O$_3$. When the UV light was switched on, the monoterpene concentration decreased sharply due to OH oxidation, as seen both from the measurements and simulation results in Fig. 5. Before the UV lights were turned on $\sim$ 80% of the reacting monoterpenes were oxidized by O$_3$. At the UV onset this number dropped to $\sim$ 10% and in the end of the UV on periods only $\sim$ 2% of the oxidized monoterpenes were oxidized by O$_3$. The modelled monoterpene concentration shows a somewhat more pronounced decrease during the UV on periods than measurement. However, as with the isoprene concentration, the relative uncertainties in the PTR-MS measurements increase at lower concentrations and part of the
Table 2. Summary of the model sensitivity tests that we performed in order to evaluate and constrain possible mechanisms for the formation and growth of nano-CN during the JPAC experiments.

<table>
<thead>
<tr>
<th>Sensitivity test category</th>
<th>Varied parameters (method) 1</th>
<th>Varied parameters (method) 2</th>
</tr>
</thead>
<tbody>
<tr>
<td>Condensable VOC properties method</td>
<td>MCMv3.2 + the Nannoolal vapour pressure method</td>
<td>2-D VBS</td>
</tr>
<tr>
<td>2-D VBS assumptions</td>
<td>Functionalization, fragmentation and OH reaction rates</td>
<td>O : C of the first generation products</td>
</tr>
<tr>
<td>Particle dry deposition loss rates</td>
<td>Varying u* in the range 0.1–0.01 m s(^{-1})</td>
<td>Influence of the UV light on the VOC composition</td>
</tr>
<tr>
<td>Gas-phase chemistry</td>
<td>Uncertainties related to the assumed NO(_x)</td>
<td></td>
</tr>
<tr>
<td></td>
<td>inflow concentration</td>
<td></td>
</tr>
<tr>
<td>Influence of ELVOCs on the particle growth</td>
<td>ELVOC formation from ozonolysis and OH-oxidation of terpenes</td>
<td></td>
</tr>
<tr>
<td>Nano-CN formation and initial growth</td>
<td>Mechanisms (Eqs. 1–6)</td>
<td>Surface tension 0.02–0.07 N m(^{-1})</td>
</tr>
<tr>
<td>Oligomerization in the particle phase</td>
<td>Peroxyhemiacetal formation, possibly acid catalysed by co-condensing H(_2)SO(_4) (Eq. 7)</td>
<td></td>
</tr>
<tr>
<td>Non-ideal mixing in the particle phase</td>
<td>Activity coefficients from AIOMFAC</td>
<td></td>
</tr>
<tr>
<td>Reversible VOC wall losses</td>
<td>With or without absorptive uptake on the glass walls</td>
<td></td>
</tr>
<tr>
<td>SOA phase-state</td>
<td>Liquid-like SOA</td>
<td>Solid-like SOA</td>
</tr>
</tbody>
</table>

Figure 5. Modelled isoprene (a), monoterpane (b), and sesquiterpene (c) concentrations together with the measured isoprene and monoterpane concentrations in the JPAC reaction chamber. In (b) we left out those monoterpenes that had a negligible contribution to the total monoterpane concentration. The purple bars indicate UV on periods during the measurements.

PTR-MS unity resolution mass peak that was interpreted as monoterpenes may also have had small contributions from other VOCs.

The sesquiterpene concentrations were below the detection limit of the PTR-MS. Our modelled results show that the sesquiterpenes were strongly oxidized by O\(_3\) once the tree emission from the plant chamber entered the reaction chamber (Fig. 3). Even when the UV lights were turned on, 40–60 % of the sesquiterpenes were oxidized by O\(_3\) and the rest by OH. The sesquiterpene concentrations decreased rapidly to below 0.01 ppbv. In addition, the sesquiterpene concentrations showed a minor decrease during UV on periods because of the oxidation by OH.

Although a large fraction of the monoterpenes and sesquiterpenes were oxidized in the JPAC reaction chamber, nano-CN formation was only observed during the UV
4.2 Simulations of the observed new particle formation events

The first simulations were designed in order to constrain the VOC wall losses and the mechanisms responsible for the observed particle growth (Sects. 4.2.1 and 4.2.2). For these simulations, we used a fixed nano-CN formation ratio of 20 cm$^{-3}$ s$^{-1}$ during the UV light on periods, except for the first 12 min with UV light on for which we used $J = 80$ cm$^{-3}$ s$^{-1}$, for Day 1 and Day 2 and 60 cm$^{-3}$ s$^{-1}$ for Day 3. During the UV light off periods the nano-CN formation rate was zero. The nano-CN had a dry diameter of 1.5 nm and was assumed to be composed of an equal number of sulfuric acid and ELVOC$_{nucl}$ molecules. After constraining the VOC wall losses and the potential particle growth mechanisms, we investigated several nano-CN formation mechanisms (Eqs. 1–6) and compared the results against the results from the simulations with a fixed nano-CN formation rate (Sect. 4.2.3).

4.2.1 Modelling the reversible VOC wall deposition

Figure 6a shows the modelled total particle volume concentration (PV) starting 14 days prior to the start of the intensive experimental campaign. The measured PV during the campaign is also displayed. The model results are from simulations with the 2-D VBS. As was described in Sect. 3.5, for the base case model simulation we used a constant species independent $k_w$ equal to 0.011 s$^{-1}$ and Eqs. (9)–(13) to differentiate between the reversible VOC wall losses to the glass and PTFE Teflon surfaces. The results in Fig. 6b and c which are from the base case simulation illustrate how the 2-D VBS compounds with different $C^*$ were distributed onto the glass walls and the PTFE Teflon floor, respectively. The LVOCs ($C_{298} < 10^{-1}$ µg m$^{-3}$) deposited both onto the glass and Teflon surfaces, while the SVOCs ($C_{298} > 10^{-1}$ µg m$^{-3}$) were exclusively found at the Teflon floor where they could absorb into $C_w$. Some of the compounds with $C_{298} = 10^{-1}$ µg m$^{-3}$ deposited on the glass walls shortly after the UV light was turned on, but when the condensation sink was increased and when the terpene inflow concentration into the reaction chamber was lowered (Day 2–Day 4), the gas-phase concentrations of these compounds never reached above their pure liquid equilibrium saturation concentrations, so they evaporated from the glass walls. Fig-

Figure 6. (a) Modelled and measured SOA volume concentration and 2-D VBS VOC wall uptake onto (b) the glass walls (Eqs. 10 and 11) and (c) the PTFE Teflon walls when considering that the PTFE Teflon walls behave as FEB Teflon walls (Eqs. 9, 12 and 13). The VOCs are summed over the all O : C but divided into the different $C^*$ bins in the 2-D VBS. At time 0 h the intensive measurement campaign started. (a) also shows the modelled SOA volume concentration when assuming that all chamber walls behave as FEP Teflon walls using Eqs. (8) and (9), $k_w = 4.2$ s$^{-1}$ and the VOC FEP Teflon wall mass accommodation coefficient parameterization from Zhang et al. (2015). ELVOC formation from Reactions (R1) and (R2) was not considered for the simulations.

on periods. This indicates that the terpene oxidation products formed during the dark periods (primarily by ozonolysis) either did not have the right properties or were not abundant enough to form, activate and/or grow nano-CN to sizes above the detection limit of the PSM-CPC setup.
Figure 7. Modelled 2-D VBS distribution for (a) the SOA particles, (b) the gas phase, (c) the VOCs on the glass walls and (d) the VOCs on the Teflon floor. The model results are from Day 3 after 5 hours with UV lights on. For this simulation Reactions (R1) and (R2) were used to simulate the ELVOC formation.

Figure 6a also shows the modelled particle volume concentration when assuming that the JPAC reaction chamber walls behave similarly to FEP Teflon walls (Eqs. 8 and 9), in which case $k_e$ was 4.2 s$^{-1}$ and the $a_w$ parameterization was taken from Zhang et al. (2015). With this parameterization, $k_{w,i}$ varies from $2 \times 10^{-5}$ to $7 \times 10^{-4}$ s$^{-1}$ for compounds with a molar mass of 300 g mol$^{-1}$ and vapour pressures in the range $10^{-2}$ to $10^{-10}$ Pa. Thus, in these model simulations the ELVOC wall losses were about 15 times lower than what was observed by Ehn et al. (2014). Because of the lower VOC wall losses, the model overestimated the SOA formation by a factor of 3–4 for Day 1, a factor of 1.5–2 for Day 2 and Day 3 and a factor of 2–3 for Day 4. There was no gradual increase in the SOA formation due to re-evaporation of SVOCs from the walls and the correlation between the model and measured PV is substantially worse. This illustrates that the wall losses in the JPAC chamber cannot be treated in the same way as in FEP smog chambers.

4.2.2 Evaluation of potential particle growth mechanisms

When using the 2-D VBS, the modelled SOA composition was dominated by LVOCs and SVOCs formed from second- and multi-generation OH-oxidation products. This was the case even if we considered that ELVOCs were formed as first generation products after the O$_3$- and OH-oxidation of all monoterpenes and sesquiterpenes (Fig. 7a). The reason

ure S8 shows similar results but for a simulation with the MCM compound SOA formation mechanism and additional ELVOCs (Reaction R1) contribution to the particle growth. After 16.5 days of continuous experiments, 1.4 mg m$^{-3}$ of SVOCs had deposited onto the PTEF Teflon floor according to the model simulations. The largest fraction of the wall deposited VOCs were first generation terpene oxidation products ($O: C = 0.4$). A fraction of these SVOCs can re-evaporate and react with OH in the gas phase. This explains why the modelled SOA formation was gradually increasing during the first 15 days (Fig. 6a), although all the other model conditions were identical. A similar pattern in the modelled SOA particle volume was also observed when the SOA formation was simulated with the MCM compound SOA formation mechanism (Sect. 3.6) (Fig. S8a). The ELVOCs (that are formed as first generation oxidation products (Reaction R1)) and the LVOCs (formed from OH-oxidation of the first generation oxidation products), primarily deposited onto the glass walls. However, in total the VOCs deposited onto the glass walls only made up 5% of the total amount of VOCs on the chamber walls.
Figure 8. Modelled and measured (a) total particle number concentration and (b) total particle volume concentration. The model results are from simulations with the 2-D VBS and with or without ELVOC formation via ozonolysis and OH-oxidation of monoterpenes and sesquiterpenes (Reactions R1 and R2), from a simulation when the MCM compounds were used as the condensable organic compounds and considering PHA dimer formation with Eq. (7), and from a simulation with only one condensable non-volatile compound. The mass yield of the non-volatile compound formed from O₃ and OH oxidation of all monoterpenes and sesquiterpenes was 60%.

For this is the large ELVOC wall losses in the JPAC chamber and the small condensation sink during the new-particle formation events. During the UV light on periods, the gas-phase 2-D VBS VOC composition was dominated by oxidized SVOCs formed by fragmentation of the first generation oxidation products (Fig. 7b).

In Fig. 8 we compare the modelled (a) total particle number concentration and (b) total particle volume concentration with the observations from the PSM-CPC and the SMPS. The model results are from simulations with the 2-D VBS with or without ELVOC formation from the ozonolysis and OH-oxidation of all monoterpenes and sesquiterpenes (Reactions R1 and R2) (molar yield of 7 and 1%, respectively), as well as from a simulation with the MCM compound SOA formation mechanism (Sect. 3.6) (including ELVOCs from the ozonolysis of α-pinene and Δ³-carene (Reaction R1)). For this simulation we also considered rapid peroxyhemiacetal dimer formation in the particle phase using Eq. (7) and $B = 200 \text{M}^{-1}\text{s}^{-1}$. Without consideration of this type of a rapid acid catalysed dimer formation process, the particle growth was substantially underestimated and almost no SOA was formed when we simulated the SOA formation with the MCM compound SOA formation mechanism (Fig. S8a). Shown in Fig. 8 are also the results from a simulation with a one-product model approach (Sect. 3.6). In the model, this non-volatile compound was formed as a first generation oxidation product from O₃ and OH oxidation of all monoterpenes and sesquiterpenes with a molar yield of 25% (mass yield of almost 60%).

In all the model simulations, the model overestimated the SOA particle volume formation during Day 1 but tended to underestimate, or to give values similar to the measurements, during the period Day 2–Day 4. The best agreement between the model and measured particle volume concentration was found with the 2-D VBS method ($R^2 = 0.699$ with ELVOCs formation and $R^2 = 0.697$ without ELVOC formation), even though the particle volume concentration could nearly equally well be represented with the MCM compound SOA formation mechanism and acid catalysed PHA dimer formation ($R^2 = 0.672$). In the simulation with the non-volatile one product model, the agreement between the modelled and measured particle volume concentration was worse ($R^2 = 0.634$), which indicates that the particle growth cannot be purely explained by condensation of ELVOCs. This model simulation also illustrates that even if the particle growth was only kinetically limited (not absorption partitioning limited) and if the yield of the formation of condensable organic compounds was the same in all the days, the decrease in SOA volume concentration from Day 1 to Day 2 should have been more pronounced because of the substan-

Figure 9. Modelled SOA volatility distribution as a function of the particle size from a simulation with the 2-D VBS and ELVOC formation from ozonolysis and OH-oxidation of monoterpenes and sesquiterpenes (Reactions R1 and R2). The results are from Day 3 after 5 h into the UV light period.

Figure 10 shows the modelled and measured particle number size distributions. The modelled and measured total particle number concentration were in good agreement with the SMPS measurements, except for the particles having a diameter < 30 nm, for which the model gave substantially higher concentrations. A contributing explanation for this feature can be non-accounted diffusion losses of particles in the SMPS inlet.

In this section we evaluate the different nano-CN formation mechanisms described in Sect. 3.2. For these simulations we used the 2-D VBS to simulate the evolution of the condensable organic compounds. For all simulations in this section, ELVOCs were formed from all the monoterpenes and sesquiterpenes oxidized by O$_3$ and OH (Reactions R1 and R2). Because the exact vapour pressures, formation mechanisms and concentrations of ELVOCs are still very uncertain, we cannot dismiss the possibility that the new particle formation (formation of particles with $D_p > 1.6$ nm) was limited by the activation of nano-CN and not by the nano-CN formation rate itself. In this section we evaluate possible nano-CN formation mechanism with the assumption that it was the nano-CN formation that primarily limited the observed new particle formation during the experiments.

Table 3 gives the coefficient of determination ($R^2$) between the modelled total particle number concentration and measured total particle number concentration ($D_p > 1.6$ nm) from the PSM-CPC setup. The $R^2$ values are only given for those nano-CN mechanisms (parameterizations) that gave a $R^2 > 0.75$. The $R^2$ values were calculated with the data from hour 11 to 96, for which the measured total particle number concentration from the PSM-CPC setup was complete. The largest $R^2$ values (> 0.95) between the modelled and measured total particle number concentration were achieved with nano-CN formation mechanisms that involves both H$_2$SO$_4$ and ELVOCs. With Eq. (3), this was the case both if the ELVOC$_\text{nuc}$ molecules were formed from OH-oxidation or OH and O$_3$ oxidation of monoterpenes and sesquiterpenes. With Eq. (4), this was only the case if the ELVOC$_\text{nuc}$ molecules were formed exclusively from ozonolysis of sesquiterpenes. These are the only mechanisms for each day of the experimental campaign. The model results are from a simulation with the 2-D VBS including ELVOC formation from all the monoterpenes and sesquiterpenes oxidized by O$_3$ and OH (Reactions R1 and R2). For Day 1, the model overestimated the particle growth rate, which can also be seen from the overestimated SOA formation (Fig. 8b). For the reminder of the experimental campaign, the modelled particle number size distributions were in good agreement with the SMPS measurements, except for the particles having a diameter < 30 nm, for which the model gave substantially higher concentrations. A contributing explanation for this feature can be non-accounted diffusion losses of particles in the SMPS inlet.

In the supplement we show how the volatility distribution of the MCM compounds and the SOA formation changed when the NO$_x$ concentration in the inflow to the chamber was varied in the range 0.05–1 ppbv (Fig. S10). When the NO$_x$ concentration was increased from 0.05 to 1 ppbv the particle SOA volume concentration was increased slightly (~ 10%).

4.2.3 Evaluation of potential nano-CN formation mechanisms

In this section we evaluate the different nano-CN formation mechanisms described in Sect. 3.2. For these simulations we used the 2-D VBS to simulate the evolution of the condensable organic compounds. For all simulations in this section, ELVOCs were formed from all the monoterpenes and sesquiterpenes oxidized by O$_3$ and OH (Reactions R1 and R2). Because the exact vapour pressures, formation mechanisms and concentrations of ELVOCs are still very uncertain, we cannot dismiss the possibility that the new particle formation (formation of particles with $D_p > 1.6$ nm) was limited by the activation of nano-CN and not by the nano-CN formation rate itself. In this section we evaluate possible nano-CN formation mechanism with the assumption that it was the nano-CN formation that primarily limited the observed new particle formation during the experiments.

Table 3 gives the coefficient of determination ($R^2$) between the modelled total particle number concentration and measured total particle number concentration ($D_p > 1.6$ nm) from the PSM-CPC setup. The $R^2$ values are only given for those nano-CN mechanisms (parameterizations) that gave a $R^2 > 0.75$. The $R^2$ values were calculated with the data from hour 11 to 96, for which the measured total particle number concentration from the PSM-CPC setup was complete. The largest $R^2$ values (> 0.95) between the modelled and measured total particle number concentration were achieved with nano-CN formation mechanisms that involves both H$_2$SO$_4$ and ELVOCs. With Eq. (3), this was the case both if the ELVOC$_\text{nuc}$ molecules were formed from OH-oxidation or OH and O$_3$ oxidation of monoterpenes and sesquiterpenes. With Eq. (4), this was only the case if the ELVOC$_\text{nuc}$ molecules were formed exclusively from ozonolysis of sesquiterpenes. These are the only mechanisms for each day of the experimental campaign. The model results are from a simulation with the 2-D VBS including ELVOC formation from all the monoterpenes and sesquiterpenes oxidized by O$_3$ and OH (Reactions R1 and R2). For Day 1, the model overestimated the particle growth rate, which can also be seen from the overestimated SOA formation (Fig. 8b). For the reminder of the experimental campaign, the modelled particle number size distributions were in good agreement with the SMPS measurements, except for the particles having a diameter < 30 nm, for which the model gave substantially higher concentrations. A contributing explanation for this feature can be non-accounted diffusion losses of particles in the SMPS inlet.

In the supplement we show how the volatility distribution of the MCM compounds and the SOA formation changed when the NO$_x$ concentration in the inflow to the chamber was varied in the range 0.05–1 ppbv (Fig. S10). When the NO$_x$ concentration was increased from 0.05 to 1 ppbv the particle SOA volume concentration was increased slightly (~ 10%).

4.2.3 Evaluation of potential nano-CN formation mechanisms

In this section we evaluate the different nano-CN formation mechanisms described in Sect. 3.2. For these simulations we used the 2-D VBS to simulate the evolution of the condensable organic compounds. For all simulations in this section, ELVOCs were formed from all the monoterpenes and sesquiterpenes oxidized by O$_3$ and OH (Reactions R1 and R2). Because the exact vapour pressures, formation mechanisms and concentrations of ELVOCs are still very uncertain, we cannot dismiss the possibility that the new particle formation (formation of particles with $D_p > 1.6$ nm) was limited by the activation of nano-CN and not by the nano-CN formation rate itself. In this section we evaluate possible nano-CN formation mechanism with the assumption that it was the nano-CN formation that primarily limited the observed new particle formation during the experiments.

Table 3 gives the coefficient of determination ($R^2$) between the modelled total particle number concentration and measured total particle number concentration ($D_p > 1.6$ nm) from the PSM-CPC setup. The $R^2$ values are only given for those nano-CN mechanisms (parameterizations) that gave a $R^2 > 0.75$. The $R^2$ values were calculated with the data from hour 11 to 96, for which the measured total particle number concentration from the PSM-CPC setup was complete. The largest $R^2$ values (> 0.95) between the modelled and measured total particle number concentration were achieved with nano-CN formation mechanisms that involves both H$_2$SO$_4$ and ELVOCs. With Eq. (3), this was the case both if the ELVOC$_\text{nuc}$ molecules were formed from OH-oxidation or OH and O$_3$ oxidation of monoterpenes and sesquiterpenes. With Eq. (4), this was only the case if the ELVOC$_\text{nuc}$ molecules were formed exclusively from ozonolysis of sesquiterpenes. These are the only mechanisms for each day of the experimental campaign. The model results are from a simulation with the 2-D VBS including ELVOC formation from all the monoterpenes and sesquiterpenes oxidized by O$_3$ and OH (Reactions R1 and R2). For Day 1, the model overestimated the particle growth rate, which can also be seen from the overestimated SOA formation (Fig. 8b). For the reminder of the experimental campaign, the modelled particle number size distributions were in good agreement with the SMPS measurements, except for the particles having a diameter < 30 nm, for which the model gave substantially higher concentrations. A contributing explanation for this feature can be non-accounted diffusion losses of particles in the SMPS inlet.

In the supplement we show how the volatility distribution of the MCM compounds and the SOA formation changed when the NO$_x$ concentration in the inflow to the chamber was varied in the range 0.05–1 ppbv (Fig. S10). When the NO$_x$ concentration was increased from 0.05 to 1 ppbv the particle SOA volume concentration was increased slightly (~ 10%).
Figure 10. Modelled and measured particle number size distribution from (a) Day 1, (b) Day 2, (c) Day 3 and (d) Day 4 of the experimental campaign. The particle number size distributions are from $\frac{1}{2}$, 1, 2 and 5 h after the UV light was turned on. The model results are from a simulation with the 2-D VBS (including ELVOC formation (Reactions R1 and R2)) and the full-moving size distribution method.

Table 3. Coefficient of determination ($R^2$) between the modelled and measured (PSM-CPC) total particle number concentration during the experimental campaign.

<table>
<thead>
<tr>
<th>Nano-CN formation mechanism</th>
<th>ELVOC$_{\text{nucl}}$ source</th>
<th>$R^2$</th>
</tr>
</thead>
<tbody>
<tr>
<td>$J = 20 \text{ cm}^{-3} \text{s}^{-1}$ when UV is on</td>
<td></td>
<td>0.937</td>
</tr>
<tr>
<td>$J = K_2 [\text{H}_2\text{SO}_4]^2$</td>
<td></td>
<td>0.787</td>
</tr>
<tr>
<td>$J = A_1 [\text{H}_2\text{SO}_4]$</td>
<td></td>
<td>0.887</td>
</tr>
<tr>
<td>$J = K_3 [\text{H}_2\text{SO}<em>4] [\text{ELVOC}</em>{\text{nucl}}]$</td>
<td>MT and SQT ox. by $\text{O}_3$ and OH (Reactions R3, R4)</td>
<td>0.951</td>
</tr>
<tr>
<td>$J = K_3 [\text{H}_2\text{SO}<em>4] [\text{ELVOC}</em>{\text{nucl}}]$</td>
<td>MT and SQT ox. OH (Reaction R4)</td>
<td>0.955</td>
</tr>
<tr>
<td>$J = K_3 [\text{H}_2\text{SO}<em>4] [\text{ELVOC}</em>{\text{nucl}}]$</td>
<td>SQT ox. by $\text{O}_3$ and OH (Reactions R3, R4)</td>
<td>0.891</td>
</tr>
<tr>
<td>$J = K_4 [\text{H}_2\text{SO}<em>4]^2 [\text{ELVOC}</em>{\text{nucl}}]$</td>
<td>SQT ox. by $\text{O}_3$ and OH (Reactions R3, R4)</td>
<td>0.92</td>
</tr>
<tr>
<td>$J = K_4 [\text{H}_2\text{SO}<em>4]^2 [\text{ELVOC}</em>{\text{nucl}}]$</td>
<td>SQT ox. by $\text{O}_3$ (Reaction R3)</td>
<td>0.951</td>
</tr>
<tr>
<td>$J = A_5 [\text{ELVOC}_{\text{nucl}}]$</td>
<td>MT and SQT ox. OH (Reaction R4)</td>
<td>0.815</td>
</tr>
</tbody>
</table>

which the values of $R^2$ were higher than in simulations with a fixed nano-CN formation rate during the UV light on periods. The relatively high $R^2$ value for the simulation with a fixed nano-CN formation rate during the UV light on period is an indication that the variability in the data set with respect to the compound(s) responsible for the nano-CN formation was too small to fully constrain the dominating nano-CN formation mechanism during the experiments. However, the data set is still useful to reject the less likely nano-CN mechanisms and to narrow down the list of possible mechanisms. For this, the $R^2$ value from the simulation with the fixed nano-CN formation rate was used as a benchmark.

In Fig. 11 we compare the modelled total particle number concentration when calculating $J$ using Eqs. (1)–(4). With Eq. (3), the ELVOC$_{\text{nucl}}$ were either assumed to be formed from ozonolysis and OH-oxidation of monoterpenes and sesquiterpenes, or only from OH-oxidation. With Eq. (4), the ELVOC$_{\text{nucl}}$ were formed from sesquiterpenes oxidized by OH. Displayed is also the result from the simulation with constant $J = 20 \text{ cm}^{-3} \text{s}^{-1}$ during the UV light on periods and $J = 0 \text{ cm}^{-3} \text{s}^{-1}$ during the UV light of periods. Based on
the relative contribution of ELVOCs to the nano-CN formation and growth was effectively suppressed due to their rapid and irreversible wall losses and the relatively high OH concentrations during the UV light on periods. In this respect, the conditions during the JPAC experiments were not directly comparable with typical conditions during new particle formation events in the atmosphere. In addition, the experimental conditions showed too small variability to fully constrain the dominating nano-CN formation and growth mechanisms. Despite these limitations, the JPAC experiments serve as a valuable data set to narrow down the list of potentially important nano-CN formation and growth mechanism over the boreal forest region.

In the lack of ELVOCs in the gas phase, one possible mechanism that can explain the initial particle growth is rapid heterogeneous dimer formation of SVOCs. In this work, we found out that acid catalysed peroxyhemiacetal formation between aldehydes and hydroperoxides may explain the observed particle growth. However, the particle growth could be modelled equally well if the SOA was formed by condensation of low-volatility second- and multi-generation OH gas-phase oxidation products simulated with a 2-D VBS approach. Thus, based on our model simulations, we cannot conclude weather the observed particle growth primarily was driven by low-volatility organic compounds formed in the gas phase or by rapid dimer formation in the particle phase. However, without the later mechanism the model fails to reproduce the observed SOA formation when using the MCMv3.2 oxidation products as condensable organic compounds.

Our results suggest that H$_2$SO$_4$ is one of the key compounds involved in the new particle formation, but cannot solely explain the new particle formation process. During the simulated experiments, the best agreement between the modelled and measured total particle number concentration was achieved when using a nano-CN formation rate of the form $J = K[H_2SO_4][ELVOC_{nucl}]$, where ELVOC$_{nucl}$ was formed as a BVOC OH oxidation product.

5 Summary and conclusion

In this study, we used the ADCHAM model to simulate the nano-CN formation and growth during an experimental campaign in the Jülich Plant Atmosphere Chamber, which focused on new particle formation induced by photochemical reactions of VOCs emitted from real plants (Dal Maso et al., 2014). With the model we evaluated potential nano-CN formation and growth mechanisms and how the VOC chamber wall losses influenced the SOA formation and composition.

Our analysis on the JPAC experiments illustrates how complex it is to design smog chamber experiments that mimic the conditions during new particle formation events in the atmosphere, in addition to which it provides useful information about what needs to be considered when designing such experiments. In this work we showed that the relative contribution of ELVOCs to the nano-CN formation and growth was effectively suppressed due to their rapid and irreversible wall losses and the relatively high OH concentrations during the UV light on periods. In this respect, the conditions during the JPAC experiments were not directly comparable with typical conditions during new particle formation events in the atmosphere. In addition, the experimental conditions showed too small variability to fully constrain the dominating nano-CN formation and growth mechanisms. Despite these limitations, the JPAC experiments serve as a valuable data set to narrow down the list of potentially important nano-CN formation and growth mechanism over the boreal forest region.

In the lack of ELVOCs in the gas phase, one possible mechanism that can explain the initial particle growth is rapid heterogeneous dimer formation of SVOCs. In this work, we found out that acid catalysed peroxyhemiacetal formation between aldehydes and hydroperoxides may explain the observed particle growth. However, the particle growth could be modelled equally well if the SOA was formed by condensation of low-volatility second- and multi-generation OH gas-phase oxidation products simulated with a 2-D VBS approach. Thus, based on our model simulations, we cannot conclude weather the observed particle growth primarily was driven by low-volatility organic compounds formed in the gas phase or by rapid dimer formation in the particle phase. However, without the later mechanism the model fails to reproduce the observed SOA formation when using the MCMv3.2 oxidation products as condensable organic compounds.

Our results suggest that H$_2$SO$_4$ is one of the key compounds involved in the new particle formation, but cannot solely explain the new particle formation process. During the simulated experiments, the best agreement between the modelled and measured total particle number concentration was achieved when using a nano-CN formation rate of the form $J = K[H_2SO_4][ELVOC_{nucl}]$, where ELVOC$_{nucl}$ was formed as a BVOC OH oxidation product.

Acknowledgements. P. Roldin would like to thank the Cryosphere-Atmosphere Interactions in a Changing Arctic Climate (CRAICC) and the Swedish Research Council for Environment, Agricultural Sciences and Spatial Planning FORMAS (Project no. 214-2014-1445) for financial support. L. Liao wishes to thank the Maj and Tor Nessling foundation for financial support (grant no. 2009362), as well as the Academy of Finland (project no. 128731). D. Mogensen would like to thank the doctoral program in Atmospheric Sciences (ATM-DP) at the University of Helsinki for financial support. We would like to acknowledge HENVI (Helsinki University Centre for Environment), The FCoE (The Centre of Excellence in Atmospheric Science – From Molecular and Biological processes to the Global Climate
(ATM)), the strategic research area MERGE (Modelling the Regional and Global Earth system) and the PEGASOS (Pan-European Gas-Aerosolsclimate interaction Study, project no. FP7-ENV-2010-265148) project. We would also like to thank Gordon McFiggans’ research group at the University of Manchester, and especially David Topping, for helpful discussions and for providing the Python script (now a publicly available function called Comp-SysProp: http://ratty.cas.manchester.ac.uk/informatics/) to calculate Nannoolal-based sub-cooled liquid equilibrium saturation vapour pressures for all organic compounds included in this paper.

Edited by: A. Laaksonen

References


